

AD-A172 728

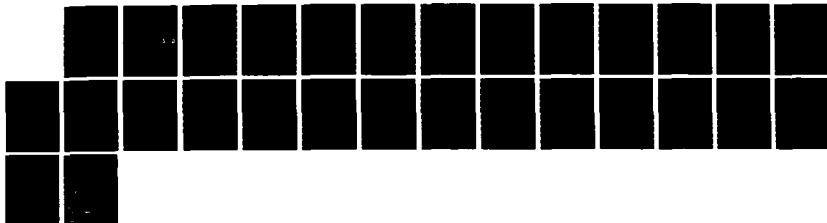
CHEMISORPTION OF CO NO AND H2 ON TRANSITION  
METAL-TITANIA THIN FILM MODEL CATALYSTS(U) TEXAS UNIV  
AT AUSTIN DEPT OF CHEMISTRY D N BELTON ET AL.  
01 SEP 86 N00014-83-K-0582

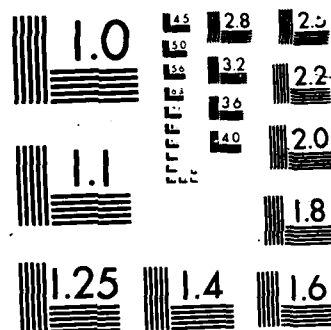
1/1

UNCLASSIFIED

F/G 7/4

NL





AD-A172 728

DTIC ACCESSION NUMBER

LEVEL

CHEMISORPTION OF CO, NO and  
H<sub>2</sub> ON TRANSITION METAL-  
TITANIA THIN FILM MODEL CATALYSTS (a)

1 Sept. 86

DOCUMENT IDENTIFICATION

PHOTOGRAPH THIS SHEET

①

INVENTORY

**DISTRIBUTION STATEMENT A**  
Approved for public release;  
Distribution Unlimited

DISTRIBUTION STATEMENT

ACCESSION FOR

NTIS GRA&I ☒

DTIC TAB ☐

UNANNOUNCED ☐

JUSTIFICATION

BY

DISTRIBUTION

AVAILABILITY CODES

DIST

AVAIL AND/OR SPECIAL

A-1

DISTRIBUTION STAMP

QUALITY  
INSPECTED  
1

DTIC  
ELECTE  
OCT 16 1986  
S D D

DATE ACCESSIONED

DATE RETURNED

86 10 14 055

DATE RECEIVED IN DTIC

REGISTERED OR CERTIFIED NO.

PHOTOGRAPH THIS SHEET AND RETURN TO DTIC-DDAC

AD-A172 728

Chemisorption of CO, NO and H<sub>2</sub>  
on Transition Metal-Titania Thin Film Model Catalysts<sup>(a)</sup>

*1 Sept. 1986*

D. N. Belton<sup>(b)</sup>, Y.-M. Sun<sup>(c)</sup> and J. M. White

Department of Chemistry

University of Texas

Austin, TX 78712

Contract N00014-83-K-0582

- (a) Supported in part by the Office of Naval Research
- (b) Present address: Physical Chemistry Department, GM Research Laboratories, Warren, MI 48090
- (c) Present address: Department of Chemistry and Chemical Engineering, Tsinghua University, Beijing, People's Republic of China

# ABSTRACT

Chemisorption on thin film models of Rh/TiO<sub>2</sub> and Pt/TiO<sub>2</sub> catalysts before and after encapsulation with TiO<sub>x</sub> ( $1.0 \leq x \leq 1.2$ ) is reported. TiO<sub>x</sub> blocks adsorption sites and induces new desorption states. A CO desorption peak, assigned to CO on Rh atoms perturbed by TiO<sub>x</sub>, is observed at 325 K after adsorption at 120K on a TiO<sub>x</sub>-covered Rh/TiO<sub>2</sub> surface. CO adsorbed at 285 K onto the encapsulated Rh/TiO<sub>2</sub> surfaces shows a new 685 K CO desorption state attributed to an activated form of CO with a weakened C-O bond. NO desorbs from clean Rh overlayers with a profile most like Rh(110). On encapsulated Rh surfaces N<sub>2</sub>O is the major desorption product. Compared to bulk Pt, desorption experiments show suppressed H<sub>2</sub> adsorption capacity for thin (<2 ML) Pt layers in contact with, but not encapsulated by, TiO<sub>x</sub>. For thin layers of Pt on fully oxidized TiO<sub>2</sub> layers there is no reduction of H<sub>2</sub> chemisorption. The results suggest bonding between Ti and Pt which affects H<sub>2</sub> chemisorption even though no Pt surface sites are blocked.

## I. INTRODUCTION

Over the last seven years strong metal support interactions (SMSI) have been extensively investigated in powder and model catalyst systems [1-13]. These investigations are predated by a number of important earlier reports [14-18]. An excellent review of the work prior to 1981 was compiled by Bond and Burch [19]. Model catalyst studies (mostly transition metals on titania) conducted after 1981 have convincingly demonstrated that SMSI involves, perhaps not exclusively, encapsulation of the active metal [9,10,20-22]. Although controversy exists about the detailed mechanism of migration, most investigators now agree that for working transition metal catalysts supported on titania in the SMSI state, the transition metal is partially covered by suboxides of Ti. Our previous work demonstrated that encapsulation suppresses hydrogen and carbon monoxide chemisorption, and that restoration occurred when the encapsulating layer was removed [22]. Those results were obtained on model catalysts formed from vapor deposited Rh on oxidized Ti. The work reported here extends those results by examining in more detail the chemisorption of CO, NO and H<sub>2</sub> on reduced and oxidized forms of titania. These systems were selected because they model SMSI catalysts and the results can be connected to widely studied systems.

Our purpose was to look carefully for interactions of TiO<sub>x</sub> with chemisorbed molecules to gain insight into the catalytic properties of SMSI catalysts. Dwyer et al. showed that TiO<sub>x</sub> on Pt inhibits CO chemisorption by a site blocking mechanism [23]. However, simple site blocking by an inert adsorbate is not sufficient to fully explain SMSI. For example, the fact that catalysts in the SMSI state exhibit increased reactivity and higher molecular weight product distributions for CO hydrogenation indicates that more than simple site blocking of CO and H<sub>2</sub> adsorption is involved [19,24].

4

The results reported here show that encapsulation has a profound effect on the desorption characteristics of both CO and NO. In addition to blocking sites,  $\text{TiO}_x$  changes the bonding of both CO and NO adsorbed on Rh. On Pt, encapsulated with  $\text{TiO}_x$ ,  $\text{H}_2$  desorption from nearest-neighbor Pt atoms is affected.

## II. EXPERIMENTAL

The experiments were performed in a turbo-pumped system equipped with Auger electron spectroscopy (AES), static secondary ion mass spectrometry (SSIMS) and temperature programmed desorption (TPD) capabilities. The model catalysts were composed of Rh (or Pt) layers vapor deposited onto an oxidized Ti(0001) single crystal (typically at 120 K). The oxide overlayer was prepared by exposing the Ti to  $5 \times 10^{-7}$  Torr of  $\text{O}_2$  at 775 K for approximately 30 minutes. The AES lineshape of the Ti(418) peak and O/Ti ratios were used to characterize the  $\text{TiO}_2$  layer. Attenuations of the Ti and O AES signals were used to estimate metal overlayer thicknesses. For the deposited Rh and Pt we estimate that about 20% of the overlayer was present as three dimensional islands on an otherwise uniform layer. Encapsulated metal layers were prepared by annealing to temperatures above 650 K. The encapsulation process was characterized with AES and SSIMS. The concentration of surface  $\text{TiO}_x$  depends on both annealing time and temperature [10,22]. Encapsulation was not observed below 600 K.

## III. RESULTS

### III.1 CO on Rh/ $\text{TiO}_2$

Metal-support interactions have been discussed in terms of the CO chemisorption properties of the supported metal; in the SMSI state CO

chemisorption is suppressed but CO hydrogenation activity is high.[1] Intuitively one might suppose that new CO adsorption sites, created by the presence of  $\text{TiO}_x$ , are responsible for the enhancement in CO hydrogenation rates observed in metal-titania systems.[24,25] The interaction of CO with  $\text{TiO}_x$  is properly characterized by comparison with CO adsorption characteristics in the absence of encapsulation. Earlier work [26] suggested that a structural rearrangement of the Rh overlayer occurred prior to encapsulation. Characterization of this rearrangement was necessary to assure that its effects were properly disentangled from encapsulation-mediated events.

Since  $\text{TiO}_x$  segregation rates vary inversely with the Rh layer thickness, a thick (120 Å) Rh layer was used to minimize encapsulation during several CO desorption experiments (maximum TPD temperatures of 620 K). After deposition of the 120 Å Rh layer onto the oxidized Ti substrate, CO (10 L, at 120 K) was adsorbed before any annealing. In the TPD spectrum (Fig. 1a) there was a broad CO desorption peak at 485 K. The desorption temperature and width are within the range observed on Rh single crystals [27-30]; however, the single crystal Rh desorption peak shapes are typically more skewed toward lower temperatures. During the first desorption experiment, the sample temperature reached 620 K, i.e. the Rh was annealed briefly. After another 10 L CO exposure, the desorption spectrum (Fig. 1b) decreased in area, changed in shape, and shifted to slightly higher temperature (at the peak). The shape of Fig. 1b more nearly resembles CO desorption from Rh single crystal surfaces than Fig. 1a. The low temperature tail and sharp drop at high temperature are characteristic of CO desorption from most Rh single crystals. Although CO desorption from Rh is not strongly structure sensitive, the low temperature shoulder on Rh(111) is



6

more pronounced than observed here, suggesting that the annealed Rh overlayer is more like Rh(100) or Rh(110).

AES data (Figs. 1c and 1d) confirm that the results of Figs. 1a and 1b were not affected by encapsulation. Immediately after deposition of the Rh overlayer, the only species observable, other than Rh, were oxygen and possibly carbon, present due to CO adsorption from the background gases during the Rh deposition. Since saturation CO exposures were studied, background CO adsorption did not affect the final result. After completion of the desorption experiments, AES data (Fig. 1d) showed neither oxygen nor titanium, indicating that during the desorption experiments no encapsulation occurred and there was no massive islanding of the Rh overlayer to expose the substrate. No other foreign atoms were detected by AES. Thus, the decreased adsorption observed in Fig. 1b (compared to 1a) is interpreted as a loss in Rh surface area. According to this interpretation, the as-deposited overlayer was comprised of three dimensional Rh islands present on top of a continuous Rh film. This roughness leads to Rh surface areas that are larger than the geometric area of the substrate. Annealing to 620 K removed some of the roughness, thereby decreasing the surface area and giving CO desorption spectra more nearly resembling those from Rh single crystals.

To eliminate these particular morphology changes from encapsulation effects, samples were annealed to 550 K prior to CO desorption experiments. This temperature was chosen because it was below the temperature where Rh/TiO<sub>2</sub> began to encapsulate and was high enough to give (reproducibly) a CO spectrum like that of Fig. 1b. In the remainder of this paper a "clean Rh/TiO<sub>2</sub> sample" refers to a sample annealed at 550 K.

To study the effect of TiO<sub>x</sub> on CO adsorption, saturation CO exposures

7

were desorbed from Rh/TiO<sub>2</sub> samples with various TiO<sub>x</sub> coverages. The latter could be increased by annealing to successively higher temperatures ( $600 \leq T \leq 760$  K) prior to CO adsorption at 120 K (Fig. 2). AES established the TiO<sub>x</sub> coverage [10]. The upper limit of the temperature ramps in TPD was 620 K in order to minimize encapsulation during TPD. Control experiments established that no CO desorption occurred above 620 K.

According to Fig. 2, TiO<sub>x</sub> affects CO desorption profiles in two ways. First, the total CO desorption peak area is reduced as the TiO<sub>x</sub> coverage is increased. Second, a new low temperature CO desorption peak (labeled  $\beta$ ) grows in as a function of TiO<sub>x</sub> coverage. The  $\beta$  desorption state is most notable after annealing to 760 K (Fig. 2d). The dashed line is a rough decomposition to reflect the clean Rh component and the broad lower temperature component. The clean surface peak was extracted by scaling down spectrum 2a with the assumption that the  $\beta$  component does not contribute significantly to desorption at 480 K. The  $\beta$  region may be composed of more than one peak, but further decomposition is not possible. The  $\beta$  desorption maximizes some 150 K below CO desorption from Rh single crystal surfaces [27,28], indicating desorption from highly perturbed Rh atoms (possibly including Ti-O-Rh species). CO desorption from clean TiO<sub>2</sub> (no Rh) peaked at  $\sim 180$  K, establishing that  $\beta$  is not desorption from the titania.

The correlation of CO desorption peak areas with Ti(418)/Rh(304) AES peak-to-peak height ratios is given in Fig. 2B. For submonolayer amounts of TiO<sub>x</sub>, the Ti/Rh AES ratios are taken to be linear in TiO<sub>x</sub> coverage. Since no calibration was possible, the absolute coverages cannot be determined. Both the  $\alpha$  and the total CO peak areas decrease linearly with TiO<sub>x</sub> coverage, but there is no detectable shift of the peak temperature of the  $\alpha$  state. This is strong evidence that simple site blocking is one important mechanism

by which  $\text{TiO}_x$  inhibits CO adsorption. The  $\beta$ -CO peak area (triangles in Fig. 2B) increases with  $\text{TiO}_x$  coverage.

These results confirm the conclusions of Dwyer et al. [23] regarding the importance of site blocking by  $\text{TiO}_x$ . The  $\beta$  desorption state has not been, to our knowledge, previously observed in SMSI systems. However, destabilization of CO by coadsorbates has been observed on Rh surfaces. For example, T. W. Root et al. [31] reported that coadsorbed N atoms decreased CO desorption temperatures by 100 K on Rh(111) and work from our laboratory shows a similar effect on Rh(100). [32] In the present case, it is not possible to determine whether the  $\beta$ -CO involves bonding to perturbed Rh atoms or to a more complex surface specie involving Rh, Ti and O. However,  $\text{TiO}_x$  is clearly responsible for the presence of these adsorption sites that are much less stable than either bridged or linearly bound CO on clean Rh.

TPD after a 10 L CO exposure at a higher temperature (285 K) onto "clean" and annealed (785 K) Rh/ $\text{TiO}_2$  samples are significantly different (Fig. 3). Figure 3a has the shape and peak temperature characteristic of desorption from clean Rh surfaces. To reiterate, the skewing to low temperature and the relatively sharp decay at temperatures above the peak are characteristic of CO desorption from Rh single crystal surfaces. No CO desorbs above 600 K.

Desorption from the sample annealed to 785 K (encapsulated) differed from the clean surface desorption in three distinct ways. First, the total CO desorption peak areas was 50% lower. This result is similar to the site blocking observed at 120 K. The second difference occurs on the low temperature side of the desorption peak where, on the encapsulated surface, the peak at 485 K is much more symmetric than on clean Rh. More quantitatively, the desorption peak half width is 57 K wider for the clean

Rh substrate. For Rh single crystals the low temperature side of the desorption peak has been associated with bridge-bonded CO [33]. If so, bridged sites are blocked on our encapsulated surfaces. While reasonable, this working hypothesis should be tested by studying CO(a) on  $\text{TiO}_x$ -covered Rh single crystal surfaces using HREELS.

The third important difference in Fig. 3 is the high temperature desorption peak, labeled  $\gamma$ , which appears at 685 K on the encapsulated surface. No desorption is observed above 600 K after dosing at 120 K on an encapsulated surface. This desorption state is not observed from single crystal or polycrystalline Rh surfaces [22,23,27-30]. Since the  $\gamma$  state was not observed when CO was adsorbed at 120 K, its formation is activated. This fact, coupled with its high temperature and broad desorption region, suggests a dissociated adsorption state. The formation of high temperature desorption states has been observed for a number of systems including potassium-covered Ni [34]. These states are commonly attributed to dissociated CO, or at least an adsorbed species with reduced C-O bond order.

Comparing Figs. 2 and 3 indicates that the  $\gamma$  state is filled slowly since CO adsorbed at 120 K is not converted during the desorption ramp of Fig. 2 (10 K/s). Another difference in Figs. 2 and 3 occurs on the low temperature side of the spectrum; there is no  $\beta$  desorption in Fig. 3. The adsorption temperature, 285 K, lies within the  $\beta$  CO desorption peak profile. Thus not all of the  $\beta$ -CO sites would have been populated. We conclude that  $\beta$  sites are not thermally stable when CO is adsorbed at 285 K and speculate that their thermal activation leads to the formation of  $\gamma$ -CO.

For comparison, we examined Rh overlayers on  $\text{Al}_2\text{O}_3$ . Upon annealing above 450 K, these layers sintered, losing surface area and exposing  $\text{Al}_2\text{O}_3$ .

This is a common occurrence for supported metals. That Rh on  $\text{TiO}_2$  becomes flatter, losing surface area, upon annealing to 600 K, is therefore significant. This result is reminiscent of microscopy results which were explained in terms of enhanced surface wetting of Pt on reduced  $\text{TiO}_2$  surfaces [4]. Regardless of the mechanistic details, reduced Ti species tend to stabilize the Rh- $\text{TiO}_2$  interface.

The linear relation between CO adsorption and  $\text{TiO}_x$  coverage (Fig. 2) supports site blocking as the primary mechanism for CO uptake reduction. This conclusion must be qualified: extensive low coverage  $\text{TiO}_x$  data was not acquired because precise control of  $\text{TiO}_x$  coverage was not possible in this regime.

Perhaps the most interesting observations are the two new CO desorption states,  $\beta$  and  $\gamma$ . The development of these desorption states on the encapsulated surface indicates that surface  $\text{TiO}_x$  is indeed affecting the surface chemistry of Rh.

### III.2 NO on Rh/ $\text{TiO}_2$

Typically NO dissociates on Rh at about 275 K [35,36,37]. Low initial NO coverages dissociate completely, desorbing as  $\text{N}_2$  and  $\text{O}_2$ . For high NO exposures, some molecular NO desorbs. Figure 4 presents the results for desorption of NO (10L, 120 K) from a clean (no encapsulation) 30 Å Rh/ $\text{TiO}_2$  sample ( $^{15}\text{NO}$  was used throughout). Two NO desorption peaks (130 and 436 K), three  $\text{N}_2$  peaks (198, 450 and 650 K), and a small  $\text{N}_2\text{O}$  peak (166 K) were detected. In repeated experiments, the high temperature  $\text{N}_2$  peak positions were constant within  $\pm 5$  K, the NO peak was always at  $436 \pm 2$  K and the area ratio  $\text{NO}/\text{N}_2$  was constant to within 20%. These variations may reflect small changes in the morphology of the Rh overlayer depending on uncontrolled

preparation details. Oxygen desorption from these surfaces was not observed because the experiments were limited to less than 800 K (oxygen desorbs from Rh at about 1200 K). The data in Fig. 4 compare quite well with NO desorption from single crystal Rh surfaces. The small  $N_2O$  peak in Fig. 4 may be either from NO decomposition on parts of the sample exposing  $TiO_2$  or from a small contaminant.[33]

After characterization of NO desorption from clean Rh surfaces, the Rh layer was encapsulated by heating to 735 K. This temperature was chosen to partially encapsulate the Rh layer with  $TiO_x$  while still providing exposed Rh atoms for NO adsorption. The TPD data (Fig. 5) shows some striking differences compared to the clean surface results. Most importantly, the low temperature  $N_2O$  desorption peak dominates the spectrum. This  $N_2O$  must be from reaction of adsorbed NO, since  $N_2O$  is, at most, only a minor contaminant in the NO supply. NO and  $N_2$  desorb at temperatures very near those observed from the clean Rh surface, but the total NO adsorption is reduced by about 50%. This is expected since  $TiO_x$  blocks surface Rh atoms. If the sample is annealed at a slightly higher temperature (760 K) for 5 minutes, NO adsorption is reduced by 80% with  $N_2O$  still the dominant peak. Since encapsulation reduces the total uptake, NO does not adsorb significantly on  $TiO_x$ . However,  $TiO_x$  does promote the dissociation of NO at low temperature.

Less than saturation NO exposures were also examined on this partially encapsulated Rh surface. NO dissociates completely upon TPD of a 0.5 L NO dose adsorbed at 110 K. While complete NO dissociation is observed on Rh single crystals, very little  $N_2O$  is observed, whereas it is the primary desorption product from encapsulated surfaces. There is no shift in the  $N_2O$  desorption temperature (150 K) as a function of NO exposure, suggesting that

$N_2O$  desorption is first order. Possible explanations are that  $N_2O$  is formed below the temperature where desorption occurs, or that  $N_2O$  desorption originates from reaction of a N-NO complex similar to that proposed for  $N_2$  formation on polycrystalline Rh.[36] Regardless of the interpretation, the important point is that  $TiO_x$  enhances low temperature NO dissociation leading to  $N_2O$  formation.

Consecutive NO desorptions were performed from the encapsulated Rh surface. Even on the fifth desorption cycle,  $N_2O$  was still the major product. The results are complicated by the continual migration of  $TiO_x$  to the Rh surface during the course of TPD. AES data taken after each of the five desorption experiments showed an increase in the Ti/Rh ratio; however, the O/Ti ratios remained nearly constant. In separate, X-ray photoelectron analysis, there is evidence for the slow oxidation of Ti to  $Ti^{4+}$ . SSIMS isotope experiments using labeled oxygen confirm that oxygen from NO does become incorporated into the  $TiO_x$  on the Rh surface. On balance, these results point to a model where at least two processes occur concurrently: (1)  $TiO_x$  is slowly oxidized to  $TiO_2$  by exposure to NO, and (2)  $N_{2O}$  is formed from NO, probably at special sites where Rh, Ti and O all interact (for example, perimeter sites).

These experiments probe the interactions in the NO-Rh- $TiO_x$  system and show a strong effect of  $TiO_x$  on Rh surface chemistry. The extent to which the effect ( $N_2O$  formation) is due to a direct  $TiO_x$ -NO interaction is not clear, but these species certainly alter the reaction paths for NO on Rh. Thus, a full description of SMSI involves more than just blocking Rh sites.

### III.3 $H_2$ on Pt/ $TiO_2$

The results from NO and CO chemisorption examined the chemistry of a

Rh-TiO<sub>x</sub> surface. One question that invariably arises is: Is the interaction long range (typically defined as beyond nearest neighbor distances) or short range? Answering questions such as this, even on ideal systems such as K/Ni(100), [34] is extremely difficult. Since our control, calibration and ability to maintain specific TiO<sub>x</sub> coverages was somewhat limited, we designed an experiment to separate site blocking effects from through-metal interactions. To do this, it was necessary to establish the metal-TiO<sub>x</sub> interaction, or bonding, without removing metal surface adsorption sites. In this experiment Pt was used instead of Rh because it is slightly more stable than Rh with respect to encapsulation. [26] Small amounts (about 1 ML) of Pt were vapor deposited on TiO<sub>2</sub> substrates (both sputter reduced and fully oxidized). Then H<sub>2</sub> was adsorbed at 120 K, followed by H<sub>2</sub> TPD. During H<sub>2</sub> desorption the maximum temperature reached was 400 K (below the temperature of encapsulation and treated here as annealing the sample). After desorption from the as-deposited Pt layer, a second 10 L H<sub>2</sub> desorption experiment was performed to confirm the first result. The desorption experiments were complemented with AES data to monitor the Pt/Ti ratio (within the AES sampling depth) during the course of the desorption experiments.

Figure 6 shows the results for the adsorption of H<sub>2</sub> onto a 0.7 ML Pt on a fully oxidized TiO<sub>2</sub> sample. Spectrum (a) is the first 10 L desorption and (b) is the second. AES data were acquired after deposition of the Pt layer and after each of the two desorptions. The desorption peak maximum (273 K in (a)) agrees well with data for 30 Å Pt/TiO<sub>2</sub> samples studied in this work, indicating no perturbation of the Pt layer by the underlying TiO<sub>2</sub> substrate. We assume no H<sub>2</sub>-Pt-TiO<sub>2</sub> reaction during desorption, which seems reasonable at these low temperatures. The second H<sub>2</sub> desorption has a different shape



and 25% less overall area than the first. The second TPD also shows two peaks, one at about 225 K and another at 295 K. AES after the second thermal desorption shows that the Pt/Ti ratio has changed from 1.6 (before the first TPD) to 1.1. The loss of surface Pt signal is discussed below.

The upper panel of Fig. 6 shows the data for 0.9 ML Pt on prereduced  $\text{TiO}_2$ ; experimental procedures were identical to those in the fully oxidized case. The entire data set was obtained in less than 10 minutes (from the time that Pt was dosed to completion of the third AES spectrum). Keeping the time as small as possible assured that CO contamination was not affecting the results. Spectrum 6c (the first desorption) is characterized by a desorption maximum (250 K) about 25 K lower than that observed for  $\text{H}_2$  desorption from thick (30 Å) clean Pt overlayers. After annealing to 400 K (the first desorption) and redosing  $\text{H}_2$ , the peak area decreased by 60% (Fig. 6d). After annealing, the peak position dropped but its determination in spectrum 6d was difficult because of the width of the very small desorption peak. A Pt/Ti AES ratio of 1.85 was observed before and after the first desorption experiment, indicating no major change in surface distribution of Pt and Ti.

Figure 6 shows that Pt supported on reduced  $\text{TiO}_2$  has reduced chemisorption capacity relative to Pt supported in fully oxidized  $\text{TiO}_2$ . Structural rearrangement of the reduced Pt/ $\text{TiO}_2$  sample was not detected by AES; therefore, encapsulation was not responsible for the 60% chemisorption suppression on the reduced sample. The change in Pt/Ti ratio observed upon annealing the oxidized Pt/ $\text{TiO}_2$  sample was easily measurable and qualitatively reproducible, indicating that a structural rearrangement (probably islanding) accounts for the 25% reduction in  $\text{H}_2$  adsorption capacity. Encapsulation of the oxidized sample is ruled out because: (1)

encapsulation was not observed below 600 K for thicker Pt on  $\text{TiO}_2$ , (2) SSIMS and AES measurements showed encapsulation occurred at lower temperatures on the reduced samples, (3) no Ti AES lineshape change was observed in the oxidized samples (a lineshape change was always observed upon encapsulation), and (4) there is good evidence for islanding of Pt on single crystal  $\text{TiO}_2(110)$  [39]. While it is not possible to rule out interdiffusion of Pt and oxidized  $\text{TiO}_2$  as responsible for the loss of surface Pt atoms, no evidence for it was found in depth profile analysis of other samples. Turning to the reduced sample, since no significant change in the AES Pt/Ti ratio was observed, while there was a 60% reduction of  $\text{H}_2$  chemisorption, we look to Pt-Ti-O chemistry. One explanation is that during annealing to 400 K (the first desorption), bonds were formed between Ti and Pt atoms that altered the chemistry of those Pt atoms. Formation of Pt-Ti bonds is proposed for three reasons: (1) 400 K is well below the temperature at which Pt oxides can be formed, (2) the surface is oxygen deficient, leaving many "unsaturated" Ti atoms, and (3) Pt-Ti bonds are 5 Kcal/mole stronger than Pt-Pt bonds [38]. Formation of Pt-Ti intermetallics is not a new concept in the field of SMSI [3].

These experiments were repeated five times. In all cases the results were qualitatively the same. The second TDS for the reduced sample showed at least a 60% decrease in  $\text{H}_2$  desorption peak area, while oxidized samples were reduced about 30%. For the reduced sample, annealing to 400 K prior  $\text{H}_2$  adsorption lowers the desorption maxima to 215 K. Annealing the oxidized samples splits the single  $\text{H}_2$  desorption peak into one at lower and one at higher temperatures.

The above data is consistent with the following phenomenology: (1) Pt deposited on reduced  $\text{TiO}_2$  at 110 K is modified slightly, yielding  $\text{H}_2$

desorption temperatures 20 K below normal, (2) when annealed to 400 K, Pt-Ti-O bonds are formed (activated process) at the Pt-TiO<sub>2</sub> interface, and (3) after formation of the Pt-Ti-O species the surface Pt atoms have significantly less affinity for H<sub>2</sub> and CO. In the absence of reduced Ti species, the Pt-support interaction is weaker, so when the system is annealed to 400 K, Pt-Pt interactions lead to some islanding. Islanding lowers the chemisorption capacity due to loss of Pt surface area. At higher temperatures (650 K), encapsulation occurs on both oxidized and reduced surfaces. However, as reported elsewhere, encapsulation is more difficult on high quality (single crystal), fully oxidized TiO<sub>2</sub> [39].

#### IV. Summary and Extrapolation

The effects of TiO<sub>x</sub> encapsulation are summarized as: (1) TiO<sub>x</sub> blocks metal atom (Pt or Rh) adsorption sites for H<sub>2</sub>, CO and NO adsorption, (2) TiO<sub>x</sub> induces a low temperature CO desorption state when CO is adsorbed at 120 K, (3) in the presence of TiO<sub>x</sub>, adsorption of CO at 285 K leads to the formation of a new form of CO that desorbs at 685 K, (4) TiO<sub>x</sub> increases the low temperature NO dissociation on Rh and enhances low temperature N<sub>2</sub>O desorption at 165 K, and (5) TiO<sub>x</sub> lying under submonolayer amounts of Pt reduces H<sub>2</sub> adsorption without blocking Pt atom adsorption sites.

These results provide direct evidence of strong chemical interactions between adsorbates and surface TiO<sub>x</sub> and confirm that TiO<sub>x</sub> is not simply a site blocking agent in SMSI catalysts. The CO and NO chemisorption results suggest that TiO<sub>x</sub> is active for dissociation reactions. These TiO<sub>x</sub>-associated dissociation sites may be associated with the enhanced methanation activity of SMSI catalysts. To confirm this speculation,

quantification of the number of  $\text{TiO}_x$  sites and correlation with methanation activity is required.

Another important result is the isolation of an effect on Pt due to the presence of underlying  $\text{TiO}_x$ . The results indicate that  $\text{TiO}_x$  can influence a Pt atom (or group of atoms) located over it.

The results from these model catalyst studies can be extrapolated to suggest the following working model for the characteristics of powder SMSI catalysts: (1) decreases in  $\text{H}_2$  and CO uptake observed upon high temperature reduction are due mainly to site blocking from encapsulating  $\text{TiO}_x$ , (2)  $\text{TiO}_x$  also modifies the surface to give new CO adsorption sites, (3) on the metal particles there are two types of sites, "clean metal" sites and highly reactive  $\text{TiO}_x$ -metal related sites, and (4) the  $\text{TiO}_x$  sites enhance CO dissociation which, in turn, enhances methanation activity.

#### References

1. S. J. Tauster, S. C. Fung and R. L. Garten, J. Am. Chem. Soc. 100(1978)1706.
2. S. J. Tauster, S. C. Fung, R. T. K. Baker and J. A. Horsley, Science 211(1981)1121.
3. J. A. Horsley, J. Am. Chem. Soc. 101(1979)2870
4. R. T. K. Baker, E. B. Prestidge and R. L. Garten, J. Catal. 56(1979)390.
5. R. T. K. Baker, E. B. Prestidge and L. L. Murrell, J. Catal. 79(1983)348.
6. M. A. Vannice and C. C. Twu, J. Catal. 82(1983)213.
7. D. E. Resasco and G. L. Haller, J. Catal. 82(1983)279.
8. R. Burch and A. R. Flambard, J. Catal. 78(1982)389.

9. H. R. Sadeghi and V. E. Henrich, J. Catal. 87(1984)279.
10. D. N. Belton, Y.-M. Sun and J. M. White, J. Phys. Chem. 88(1984)5172.
11. Metal-Support and Metal Additive Effects in Catalysis, B. Imelik et al., eds., Elsevier (Amsterdam 1982).
12. Y.-W. Chung, G. Siong and C. C. Kao, J. Catal. 85(1984)237.
13. X.-Z Jiang, T. F. Haden and J. A. Dumesic, J. Catal. 83(1983)168.
14. G. C. Bond, "Catalysis by Metals." Academic Press, London/New York, 1962.
15. R. L. Moss and L. Whalley, Advances in Catalysis and Related Subjects, 22(1972)115.
16. K. Hauffe in "Semiconductor Surface Physics" (R. H. Kingston, Ed.) Univ. of Pennsylvania Press, 1957, p. 259.
17. Th. Wolkenstein, Adv. in Catalysis and Related Subjects, 12(1960)189.
18. F. Solymosi, Catal. Rev. 1(1967)233.
19. G. C. Bond and R. Burch, Catalysis 6(1983)27.
20. Y.-W. Chung and S. Takatani, J. Catal. 90(1984)75.
21. R. T. K. Baker, J. J. Chuldzinski and J. A. Dumesic, J. Catal. 93(1985)312.
22. D. N. Belton, Y.-M. Sun and J. M. White, J. Am. Chem. Soc. 106(1984)3059.
23. D. J. Dwyer, S. D. Cameron and J. L. Gland, J. Vac. Sci. Technol. A3(1985)1569.
24. M. A. Vannice, C. C. Twu and S. H. Moon, J. Catal. 79(1983)70.
25. S.-M. Fang, J. M. White and J. G. Ekerdt, J. Catal. (in press).
26. D. N. Belton, Ph.D. Dissertation, University of Texas at Austin, 1985.
27. Y. Zhu and L. D. Schmidt, Surface Sci. 129(1983)107.
28. P. A. Thiel, E. D. Williams, J. T. Yates, Jr. and W. H. Weinberg,

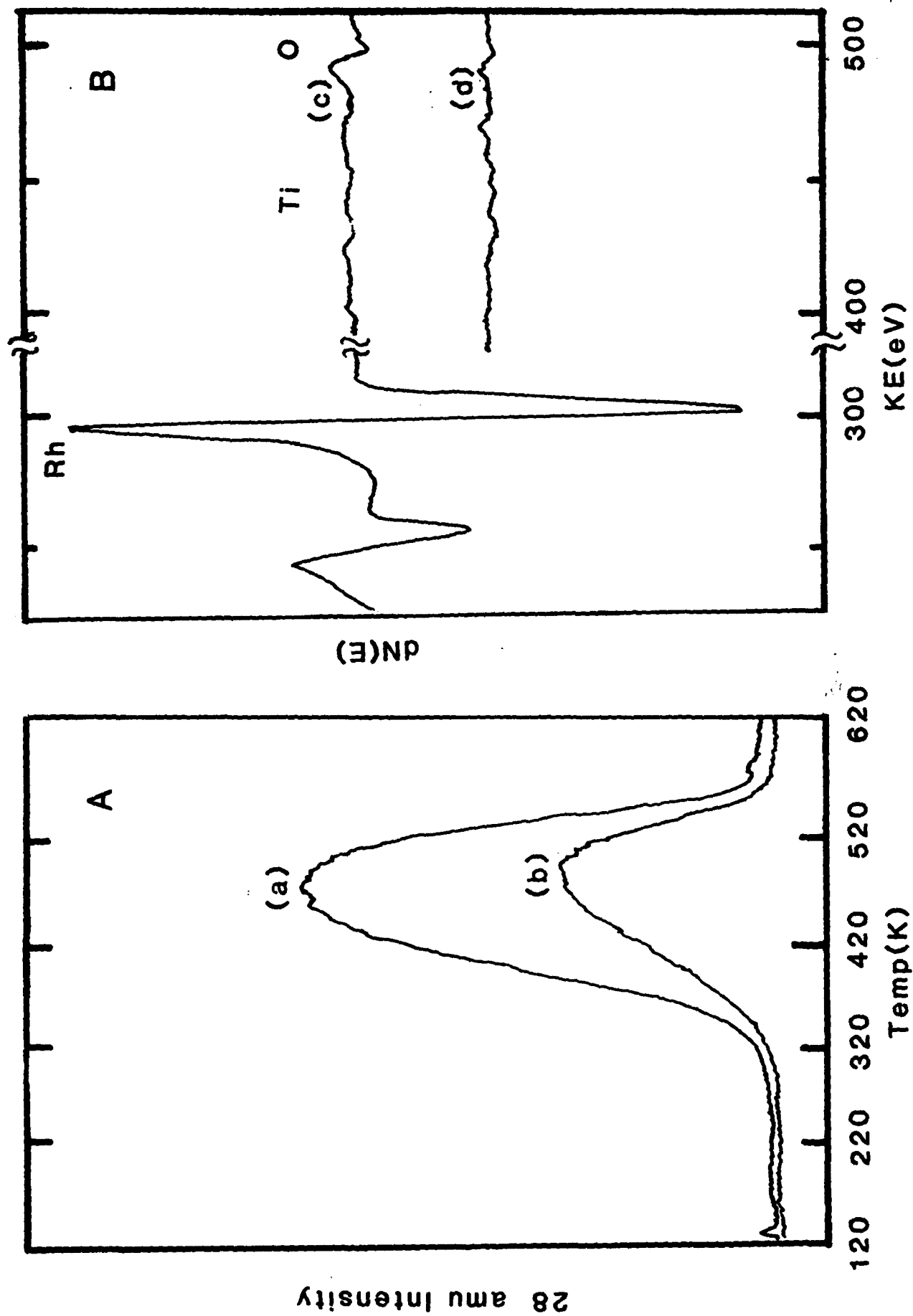
Surface Sci. 84(1979)54.

29. R. J. Baird, R. C. Ku and P. Wynblatt, Surface Sci. 97(1980)346.
30. Y. Kim, H. C. Peebles and J. M. White, Surface Sci. 114(1982)313.
31. T. W. Root, L. D. Schmidt and G. B. Fisher, Surface Sci. 150(1985)173.
32. W. M. Daniel and J. M. White, Surface Sci. (in press).
33. T. W. Root, G. B. Fisher and L. D. Schmidt (submitted).
34. H. S. Luftman, Y.-M. Sun and J. M. White, Appl. Surf. Sci. 19(1984)59.
35. T. W. Root, L. D. Schmidt and G. B. Fisher, Surface Sci. 134(1983) 30.
36. C. T. Campbell and J. M. White, Appl. Surf. Sci. 1(1978)347.
37. P. Ho and J. M. White, Surface Sci. 137(1984)117.
38. M. S. Spencer, Surface Sci. 145(1984)145.
39. Y.-M. Sun, D. N. Belton and J. M. White, J. Phys. Chem. (in press).

## FIGURE CAPTIONS

- Fig. 1. TDS (Panel A) of 10 L CO adsorbed at 120K onto a 120 Å Rh/TiO<sub>2</sub> sample. Spectrum (a) is the first desorption from the sample and spectrum (b) is the second. Panel B gives AES data before the first desorption (c) and after the second desorption (d).
- Fig. 2. TDS of 10 L CO from a 30 Å Rh/TiO<sub>2</sub> sample. In the TDS data of the left-hand panel, the sample was annealed to: (a) 600 K, (b) 650 K, (c) 700 K and (d) 760 K. The right-hand panel plots CO desorption peak areas vs. Ti/Rh AES ratios. The measured peak areas are normalized to the desorption area of spectrum (a) in the left-hand panel. The triangles denote the  $\beta$  state.
- Fig. 3. TDS of 10 L CO adsorbed at 270 K onto a 30 Å Rh/TiO<sub>2</sub> sample. Spectrum (a) is CO desorption from the as-deposited Rh layer and (b) is desorption from the Rh/TiO<sub>2</sub> sample after annealing to 780 K prior to CO adsorption at 270 K.
- Fig. 4. TDS of 10 L <sup>15</sup>N<sub>2</sub> adsorbed at 110 K onto a 30 Å Rh/TiO<sub>2</sub> sample. The sample was annealed to 525 K (no encapsulation) prior to N<sub>2</sub> adsorption.
- Fig. 5. TDS of 10 L <sup>15</sup>N<sub>2</sub> adsorbed at 110 K onto a 30 Å Rh/TiO<sub>2</sub> sample which was annealed to 735 K (encapsulation) prior to N<sub>2</sub> adsorption.
- Fig. 6. Two consecutive 10 L H<sub>2</sub> TDS from ~1 ML Pt/TiO<sub>2</sub> samples. Desorption data are for Pt supported on reduced TiO<sub>2</sub>(r) (top panel) and oxidized TiO<sub>2</sub>(o) (lower panel). Spectrum (a) is before (b) and spectrum (c) before (d).

Fig. 1





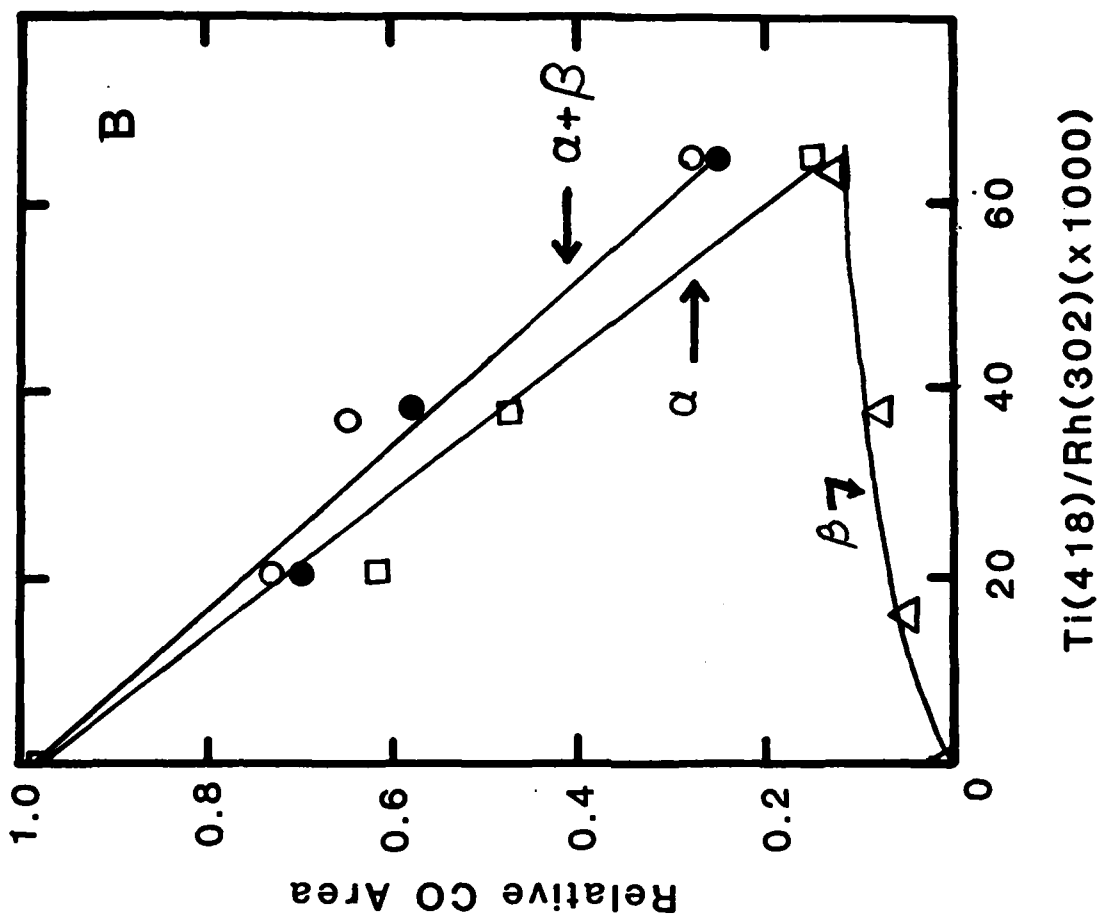
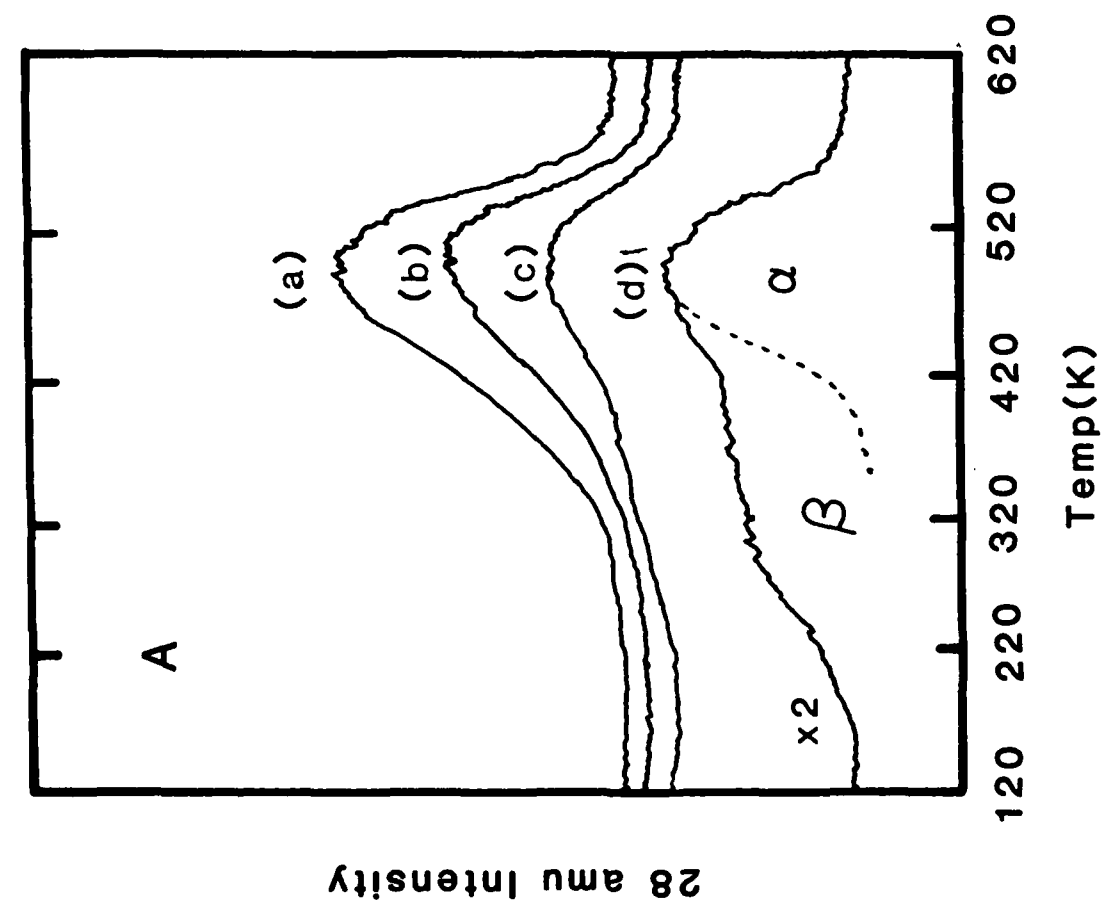


FIG. 2

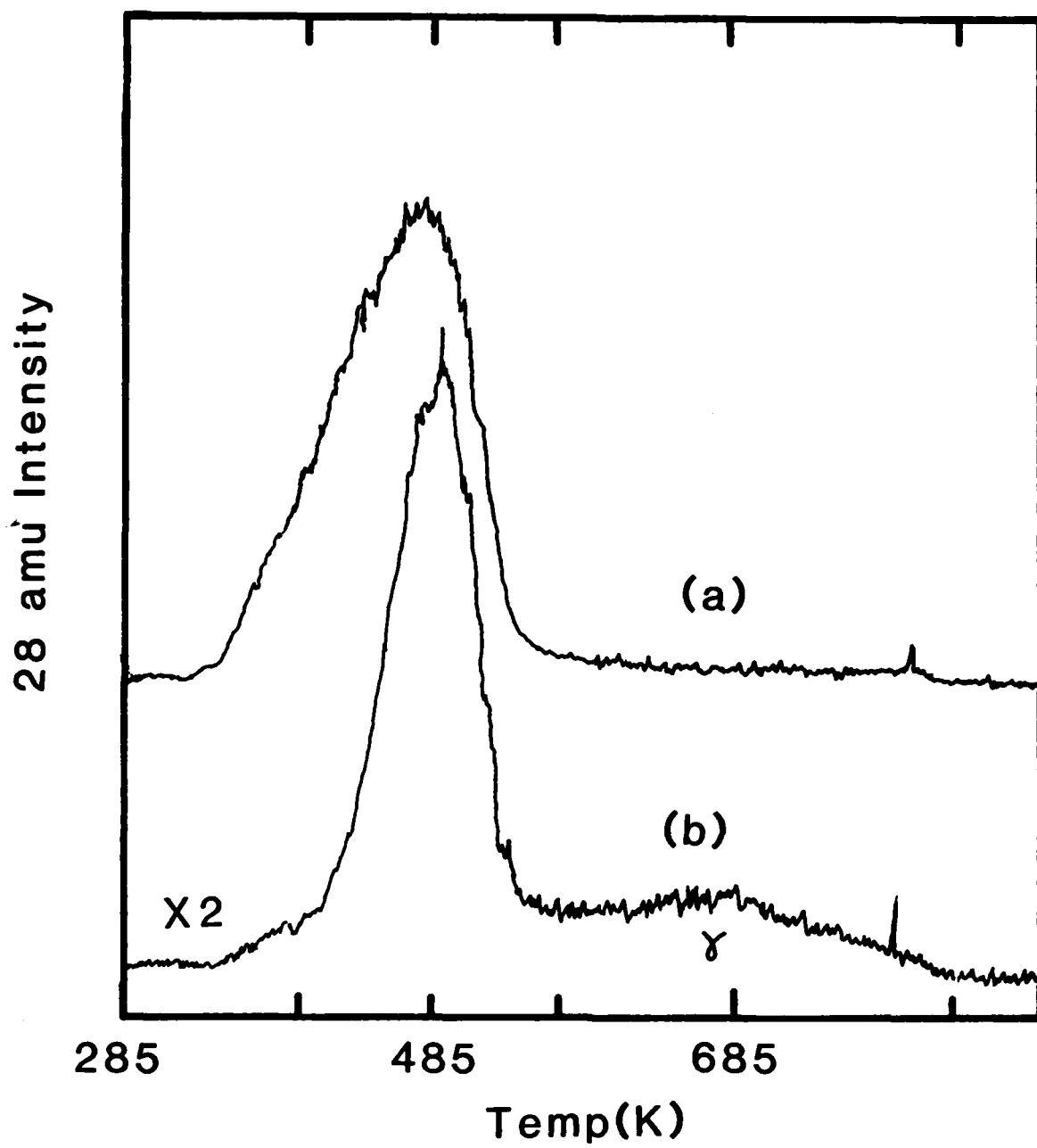
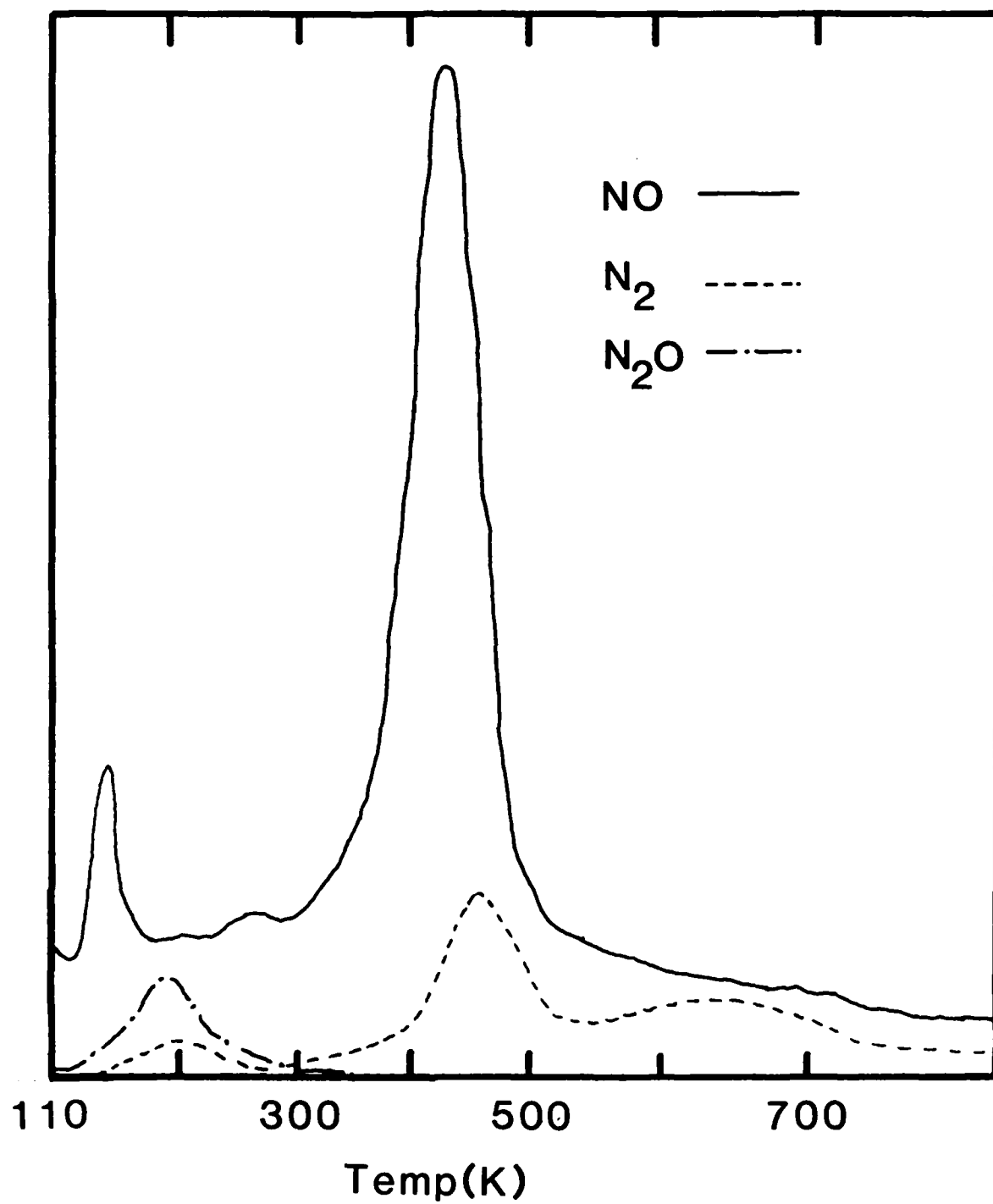


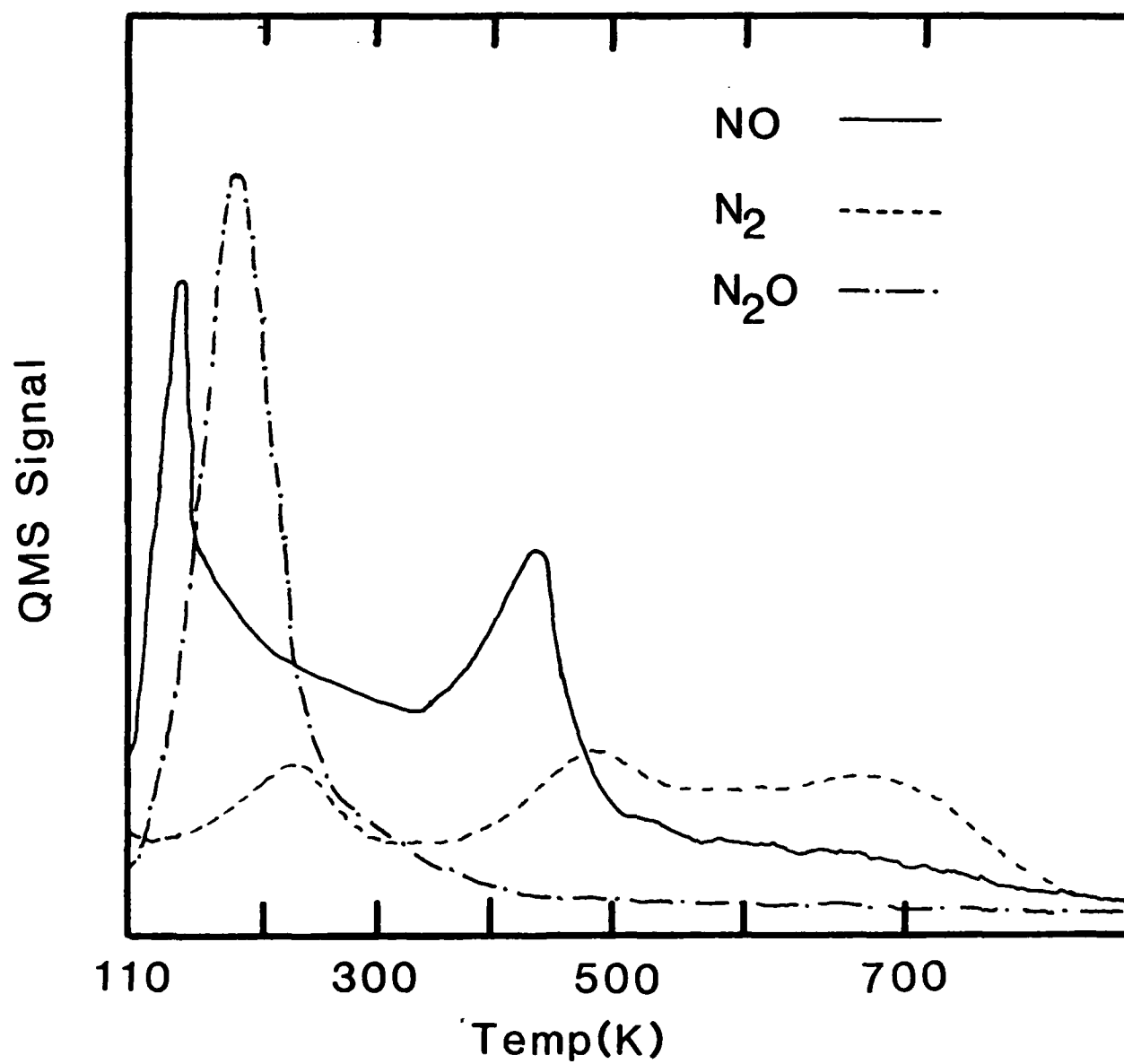
Fig. 3

QMS Signal



604

FIG 5



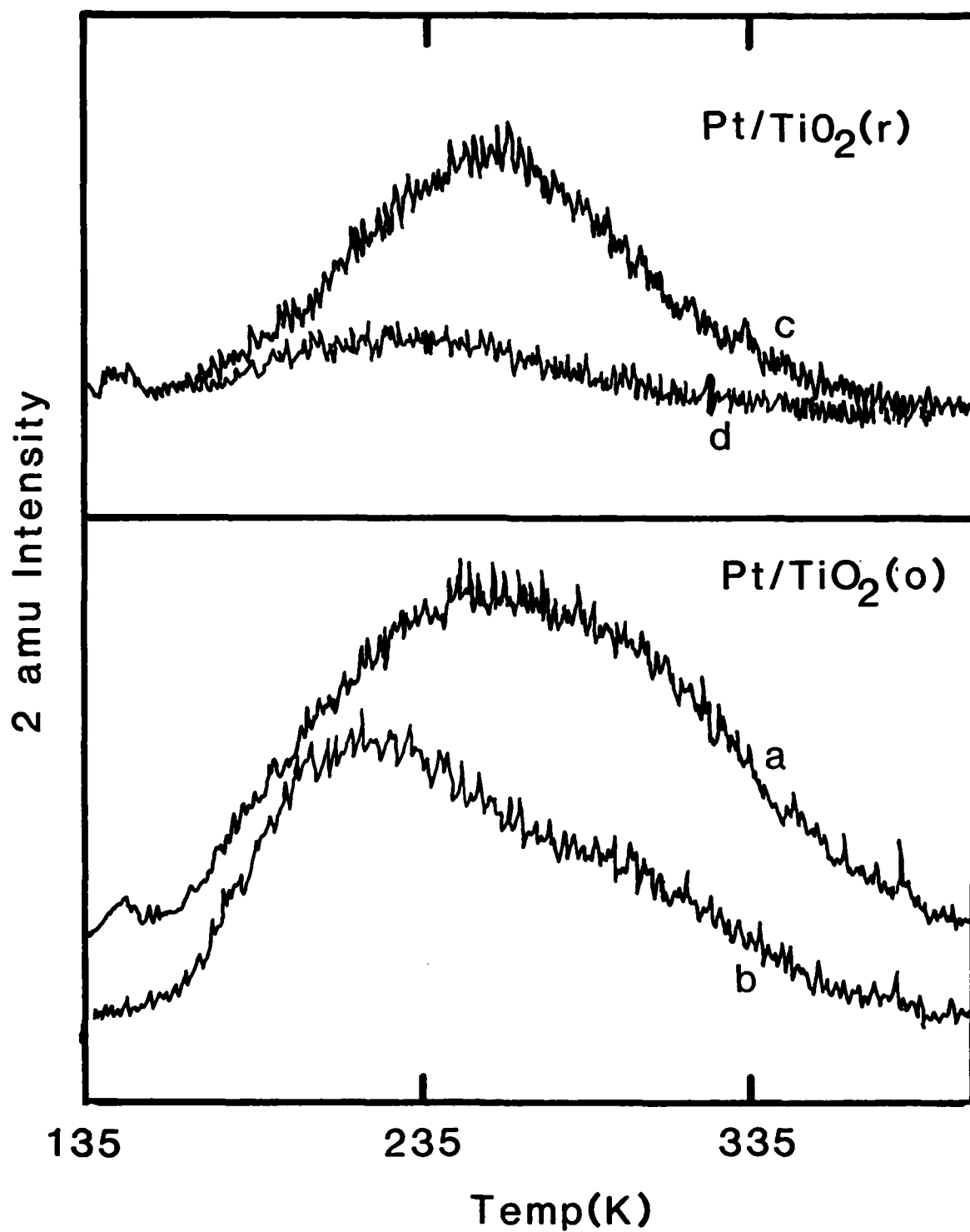


Fig. 6

END

11-56

DTIC